

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant	:	Watanabe et al.
Appl. No.	:	10/574,073
Filed	:	March 30, 2006
For	:	RESIST COMPOSITION FOR ELECTRON BEAM OR EUV
Examiner	:	Walke, Amanda
Group Art Unit	:	1752

**AMENDMENT AND RESPONSE TO FINAL OFFICE ACTION****Mail Stop AF**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

In response to the final Office Action mailed **December 17, 2007**, please amend the above-referenced application as follows:

**Amendments to the Claims** are reflected in the listing of claims, which begins on page 2 of this paper.

**Remarks** begin on page 6 of this paper.